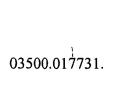
IFW 2812





## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re App	olication of:	)	
	•	:	Examiner: Michael Lebentritt
<b>HIDEY</b>	KUMOMI ET AL.	)	
	63,	:	Group Art Unit: 2812
Applicati	ion No.: 10/533,091	)	-
	-	:	
Filed: Ap	oril 28, 2005	)	
	·	:	
For:	PRODUCING METHOD FOR		
	CRYSTALLINE THIN FILM	)	August 29, 2006

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## **INFORMATION DISCLOSURE STATEMENT**

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Copies of the listed foreign documents and articles are also enclosed.

The concise explanation of relevance for the non-English document is found in the specification where cited, and in an attached abstract.

## **CONCLUSION**

It is respectfully requested that the above information be considered by the Examiner and that an initialed copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

Peter Saxon

Attorney for Applicants Registration No.: 24,947

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza
New York, New York 10112-3800
Facsimile: (212) 218-2200

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	PATEN	EPARTMENT OF COMMERC NT AND TRADEMARK OFFIC ERENCES CITED BY APPO e several sheets if necessary)	CE 3 0 7006	APPI	LICANT				
LIST	OF REF	ERENCES CITED BY APPO	MANT(S)	<u> </u>	HIDEYA KUMO	MI, ET	AL.		
	(036	Several streets if necessary,	TRADO	FILING DATE			GROUP		
					April 28, 2005		28	312	
	Γ	T	<del></del>	U.S. PA	ATENT DOCUMENTS	<del></del>	•		
*EXAMINER INITIAL	ļ	DOCUMENT NUMBER	DATE		NAME	CLAS	S SUBCLASS	FILING DATE IF APPROPRIATE	
		5,130,103	07/14/92		Yamagata et al.	428	209		
	<u> </u>	5,207,863	05/04/93		Kumomi	156	603		
		5,290,712	03/01/94		Sato, et al.	437	24		
		5,723,348	03/03/98		Kumomi et al.	437	23	,	
			FC	REIGN	PATENT DOCUMENTS				
		DOCUMENT NUMBER	DATE		COUNTRY	CLASS	S SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT	
*	JP	8-8197	01/12/96		Japan			Abstract	
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		С	THER DOCUMENT(S	(Includ	ding Author, Title, Date, Pertinent Pages, Etc.)				
	Kumomi, et al. "Selective Nucleation-based Epitaxy (SENTAXY): A novel Approach for Thin Film Formation"; JPN J. Appl. Phys., Vol. 36 pp 1383-1388 (1997).								
		Kumomi, et al. "Fundamentals for the Formation and Structure Control of Thin Films: Nucleation, Growth, Solid-state Transformations"; Handbook of Thin Film Materials, Vol. 7, Ch. 6, pp 319-373 (2002).							
		Hatano, et al. "Excimer Laser-induced Temperature Field in Melting and Resolidification of Silicon Thin Films"; J. Appl. Phys., Vol. 87, No. 1, pp. 36-43 (2000).							
		Van der Wilt, et al. "Formation of Location-controlled Crystalline Islands Using Substrate- embedded Seeds in Excimer-laser Crystallization of Silicon Films"; Appl. Phys. Lett, Vol. 79, No. 12, pp 1819-1821 (2001)							
EXAMINER					DATE CONSIDERED		<del></del>		

She	et	1	of	1

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.